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# PROCEEDINGS OF SPIE

*2013 International Conference on Optical  
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## **Micro/Nano Photonics and Fabrication**

**Zhiping Zhou**  
**Changhe Zhou**  
*Editors*

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# Contents

v	<i>Symposium Committee</i>
vii	<i>Conference Committee</i>
ix	<i>Introduction</i>

---

## NANOMATERIALS, PLASMONICS, AND METAMATERIALS

---

- 9047 02 **Demonstration of femtosecond soliton dynamics in silicon photonic nano-wire waveguide** [9047-15]  
J. Liao, X. Li, National Univ. of Defense Technology (China); M. D. Marko, Columbia Univ. (United States) and Navy Air Warfare Ctr. Aircraft Div. (United States); H. Jia, J. Liu, J. Yang, Y. Tan, X. Wang, Y. Zhang, W. Tang, National Univ. of Defense Technology (China)
- 9047 03 **Near-field observations of surface plasmon excitation in photon-plasmon coupling structure** [9047-21]  
X. Zhang, Huaqiao Univ. (China); Z. Ma, Zhejiang Communication Services Co. Ltd. (China); L. Tong, Zhejiang Univ. (China)
- 9047 04 **An alternative method to configure terahertz response by electric-field-coupled metamaterials** [9047-26]  
Y. Wen, W. Ma, X. Yu, Peking Univ. (China)
- 9047 05 **Terminal interface effect in metal-dielectric multilayer** [9047-27]  
J. Hu, T. Ren, G. Wang, W. Gao, Hefei Univ. of Technology (China); J. Chen, Southwest Univ. of Science and Technology (China); F. Gao, Hefei Univ. of Technology (China); H. Ming, Univ. of Science and Technology of China (China)

---

## LASER ASSISTED FABRICATION AND PHENOMENON

---

- 9047 06 **Influence of growth temperature on the properties of Al-doped ZnO thin film fabricated by pulsed laser deposition** [9047-9]  
Y. Zhou, Hebei Univ. (China); H. Zheng, Baoding Univ. (China); L. Zhang, Y. Peng, Q. Zhao, B. Liu, Hebei Univ. (China)
- 9047 07 **Influence of hole diameter on the average size and quantity distribution of Si nanoparticles** [9047-20]  
L. Chu, Y. Zong, Z. Deng, X. Ding, Hebei Univ. (China); H. Zhao, Hebei Univ. of Technology (China); Y. Wang, Hebei Univ. (China)
- 9047 08 **Laser alchemy: direct writing of multifunctional components in a glass chip with femtosecond laser pulses (Invited Paper)** [9047-38]  
Y. Liao, J. Lin, Y. Cheng, Shanghai Institute of Optics and Fine Mechanics (China)

---

## NANOSTRUCTURE FABRICATION AND APPLICATION

---

- 9047 09 **Linear and passive silicon diodes, isolators, and logic gates (Invited Paper)** [9047-100]  
Z.-Y. Li, Institute of Physics (China)
- 9047 0A **Si surface texture by pyramid structure ZnO glass mask blank** [9047-11]  
J. Wang, H. Feng, C. Jin, Z. Zhang, W. Lai, W. Yu, G. Fu, Hebei Univ. (China)
- 9047 0B **Active terahertz holography** [9047-33]  
Z. Xie, Harbin Institute of Technology (China); X. Wang, Capital Normal Univ. (China);  
Y. Zhang, Harbin Institute of Technology (China) and Capital Normal Univ. (China)
- 9047 0C **Groove profile modification of convex blazed gratings by dip (spin) coating with photoresist** [9047-17]  
Y. Cheng, Q. Liu, J. Wu, Soochow Univ. (China)
- 9047 0D **High performance and compact polarization beam splitter based on silicon-on-insulator subwavelength grating coupler** [9047-34]  
J. Yang, National Univ of Defense Technology (China) and Peking Univ. (China); Z. Shao,  
K. Zhou, S. Xu, J. Xu, National Univ. of Defense Technology (China)

---

## POSTER SESSION

---

- 9047 0E **Optical property of Eu-doped ZnO films** [9047-16]  
H. Yang, X. Teng, W. Yu, Z. Zhang, X. Li, Hebei Univ. (China)
- 9047 0F **The fabrication of the holographic dual-blazed grating** [9047-19]  
Q. Liu, J. Wu, M. Chen, Y. Cheng, Soochow Univ. (China)
- 9047 0G **Fabry-Perot color filter with antireflective nano-grating surface** [9047-25]  
J. Zhang, J. Zhang, X. Dong, Soochow Univ. (China)
- 9047 0H **Analysis of the spatial chirp in the ultrashort pulsed finite beam diffraction by the volume Bragg grating** [9047-29]  
B. Qiu, B. Xiong, S. Wu, G. Zhang, K. Zou, X. Yuan, Soochow Univ. (China)
- 9047 0I **Design and fabrication of micro-bolometer array with double layers structure** [9047-30]  
J. Wang, J. Gou, W. Li, D. Gu, Y. Jiang, Univ. of Electronic Science and Technology of China (China)
- 9047 0J **Talbot effect under illuminated by ultrashort laser pulses with complex spectral distribution** [9047-32]  
W. Wang, H. Zhu, Z. Liang, J. Chen, C. Yi, Shandong Jiaotong Univ. (China)
- 9047 0K **Reactive ion etching and OES endpoint detection of AlCu thin film** [9047-35]  
J. Gou, H. L. Tai, J. Wang, X. B. Wei, Y. D. Jiang, Univ. of Electronic Science and Technology of China (China)

*Author Index*

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**Yanqiu Li**, Beijing Institute of Technology (China)
- 4 Nanostructure Fabrication and Application  
**Xingjun Wang**, Peking University (China)  
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## Introduction

The tremendous demand on high-density data communications, real time sensing/detection, and high-speed control/actuation has heated up the research and development in micro/nano photonics, which studies the behavior of light on the micro/nanometer scale and deals with high bandwidth, high speed, and ultrasmall optoelectronic components. On the other hand, the micro/nano structures used in micro/nano photonics require highly accurate and reproducible size control, which makes it a great challenge for the fabrication technology.

In this regard, the Micro/Nano Photonics and Fabrication Conference of OIT' 2013 was organized. The conference accepted over 30 papers from different countries/areas of the world, which are focused on the design, fabrication, and application of micro/nanostructures, and crossed many research disciplines including silicon photonics integration, active nanomaterials, metamaterials, nanostructure device, and fabrication technology. During the conference, novel materials, such as carbon nanotube, were discussed, newest fabrication technologies, such as untrafast laser fabrication, were reviewed, and quite a few invited papers showed exciting achievements. It is a great pleasure to see many most recent progresses in micro/nano photonics and fabrication were presented in this conference.

As the committee chairs, we would like to express our appreciation to the committee members for their support, to the presenters for devoting their precious time to write the intriguing articles, and to the reviewers for their helpful comments. We are also grateful to the SPIE staff for their efforts in publishing this Proceedings volume.

**Zhiping Zhou**  
**Changhe Zhou**

